

D. J.  
#2 11-16-01

IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

Applicant(s): STENSMO

Art Unit: TD Unk. *DS w/Refer*

Serial No.: Unk.

Examiner: Unk.

Filing Date: Herewith

Atty. Docket#: ARC920000150US1

For: SYSTEM AND METHOD FOR CONTEXT-  
DEPENDENT PROBABILISTIC MODELING OF  
WORDS AND DOCUMENTS

March 29, 2001  
750 "B" Street, Suite 3120  
San Diego, CA 92101

INFORMATION DISCLOSURE STATEMENT

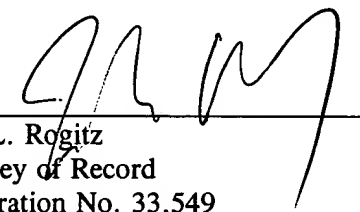
Assistant Commissioner for Patents  
Washington, DC 20231



Dear Sir:

Pursuant to Sections 1.97, 1.98, and 1.99 of the Rules of Practice in patent cases, enclosed are copies of the references and patents cited on the "List of References Cited by Applicant," Form PTO-1449, submitted herewith.

Respectfully submitted,

  
\_\_\_\_\_  
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JLR/jg  
Encs.

<b>Form PTO-1449 (modified)</b>  <b>LIST OF PATENTS AND PUBLICATIONS FOR APPLICANT(S)' INFORMATION DISCLOSURE STATEMENT</b>  <i>(Use several sheets if necessary)</i>	<b>Attorney Docket No.</b> ARC920000150 US1	<b>Serial No.</b>  STENSMO
	<b>Applicant(s):</b>	
	<b>Filing Date:</b> Herewith	<b>Group Art Unit:</b>



## U.S. PATENT DOCUMENTS

Examiner Initials	Document No.	Date	Name	Class	Subclass	Filing Date
	5,809,496	09/15/98	Byrd, Jr. et al.	707	5	
	5,918,240	06/29/99	Kupiec et al.	707	531	
	5,778,397	07/07/98	Kupiec et al.	707	500	
	5,023,912	06/11/91	Segawa	381	43	
	4,905,287	02/27/90	Segawa	381	43	

## FOREIGN PATENT DOCUMENTS

Examiner Initials	Document No.	Date	Country	Class	Subclass	Translation Yes No
	EP0241183A1	14.10.87	Europe	G10L		Yes
	EP0539749A2	05.05.93	Europe	G06K9		Yes
	WO 97/46998	11.12.97	WIPO	G10L		Yes
	JP11338883A	10.12.99	JAPAN			Partial

Examiner Initials	Citation

Examiner

Date Considered

Examiner: Initial if reference considered, whether or not citation is in conformance with MPEP 609. Draw line through citation if not in conformance and not considered. Include copy of this form with next communication to applicant(s).